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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Masahiro FURUKAWA et al.

Group Art Unit: 1755

Application No.: 10/531,048

Docket No.: 123487

Filed: April 12, 2005

For:

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Respectfully submitted,

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Date: January 23, 2007

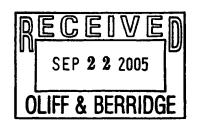
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FILING OR 371 APPL NO. **ART UNIT FIL FEE REC'D** ATTY.DOCKET NO DRAWINGS TOT CLMS (c) DATE IND CLMS 10/531,048 04/12/2005 1754 900 123487 11 3

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CONFIRMATION NO. 4675

FILING RECEIPT *OC000000017002890*

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Applicant(s)

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Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/13189 10/15/2003

Foreign Applications

JAPAN 2002-303923 10/18/2002

Projected Publication Date: 12/22/2005

Non-Publication Request: No

Early Publication Request: No

Title

Silicon carbide-based catalytic material and process for producing the same

502

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